Freeform Search

| DATE: Monda | Search History ay, April 25, 2005 Printable Copy Create Case | |
|-------------|--|--|
| | Search History | |
| | | |
| | Search | |
| Generate: | : C Hit List 6 Hit Count C Side by Side C Image | |
| Display: | Documents in <u>Display Format</u> : - Starting with Number 1 | |
| Term: | L3 and (reus\$4 or recycl\$3 or repeat\$3 or reclaim\$5) | |
| Database. | EPO Abstracts Database JPO Abstracts Database Derwent World Patents Index IBM Technical Disclosure Bulletins | |

END OF SEARCH HISTORY

L1 and residue

L1 and (smart adj cut)

L3

L2

<u>L1</u>

DB=PGPB, USPT, USOC, EPAB, JPAB, DWPI, TDBD; PLUR=YES; OP=OR

(wafer with bond\$3) and (wafer with (separat\$3 or delaminat\$4 or detach\$5 or split\$4)) and implant\$5 and (polish\$4 or CMP) and (rough\$4 or uniform\$3 or

L3 and (reus\$4 or recycl\$3 or repeat\$3 or reclaim\$5)

non-uniform\$3 or nonuniform\$3 or smooth\$4)

L4

<u>L3</u>

<u>L2</u>

L1

69

148

88

888